

Project: IEEE P802.15 Working Group for Wireless Personal Area Networks (WPANs)

Submission Title: Active MMIC Technology for 240 GHz Wireless Data Links

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Source: Ingmar Kallfass, Fraunhofer Institute for Applied Solid-State Physics

Address: Tullastrasse 72, D-79108 Freiburg, Germany

Voice: +49 761 5159 486, FAX: +49 761 5159 71486, E-Mail: ingmar.kallfass@iaf.fraunhofer.de

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Abstract: Active Monolithic Millimeter-wave Integrated Circuits are today covering the entire millimeter-wave frequency range and enable highly compact and cost-efficient analog frontends. This contribution presents MMIC technology and components dedicated to broadband wireless communication between 200 and 300 GHz. First link demonstrations based on multi-functional MMIC transmitters and receivers are shown.

Purpose: Proof of concept of broadband active transmit and receive MMIC components for wireless data transmission in the frequency range from 200 to 300 GHz.

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Active MMIC Technology for 240 GHz Wireless Data Links

Ingmar Kallfass^{1,2}, Daniel Lopez-Diaz¹, Sebastian Diebold², Jochen Antes²
Axel Tessmann¹, Arnulf Leuther¹

¹ Fraunhofer Institute for Applied Solid-State Physics, Freiburg, Germany

² Karlsruhe Institute of Technology, Karlsruhe, Germany

Outline

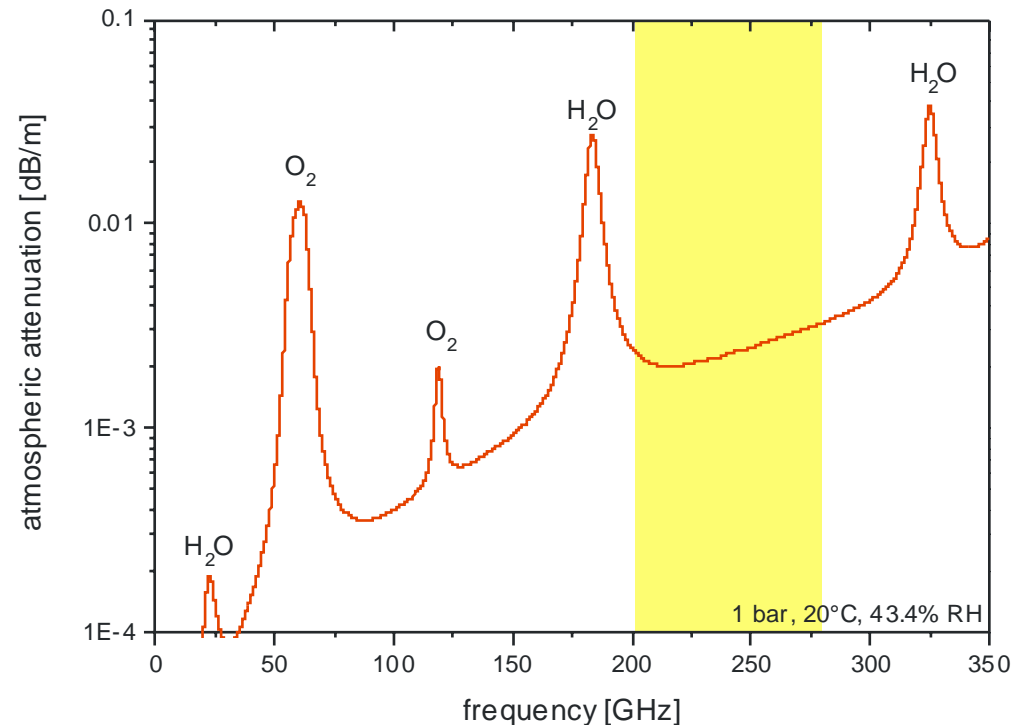
- Introduction
- Frontend Architecture
- Enabling MMIC Technology
- MMICs for Broadband Communication
- First 220 GHz Link Demonstrations

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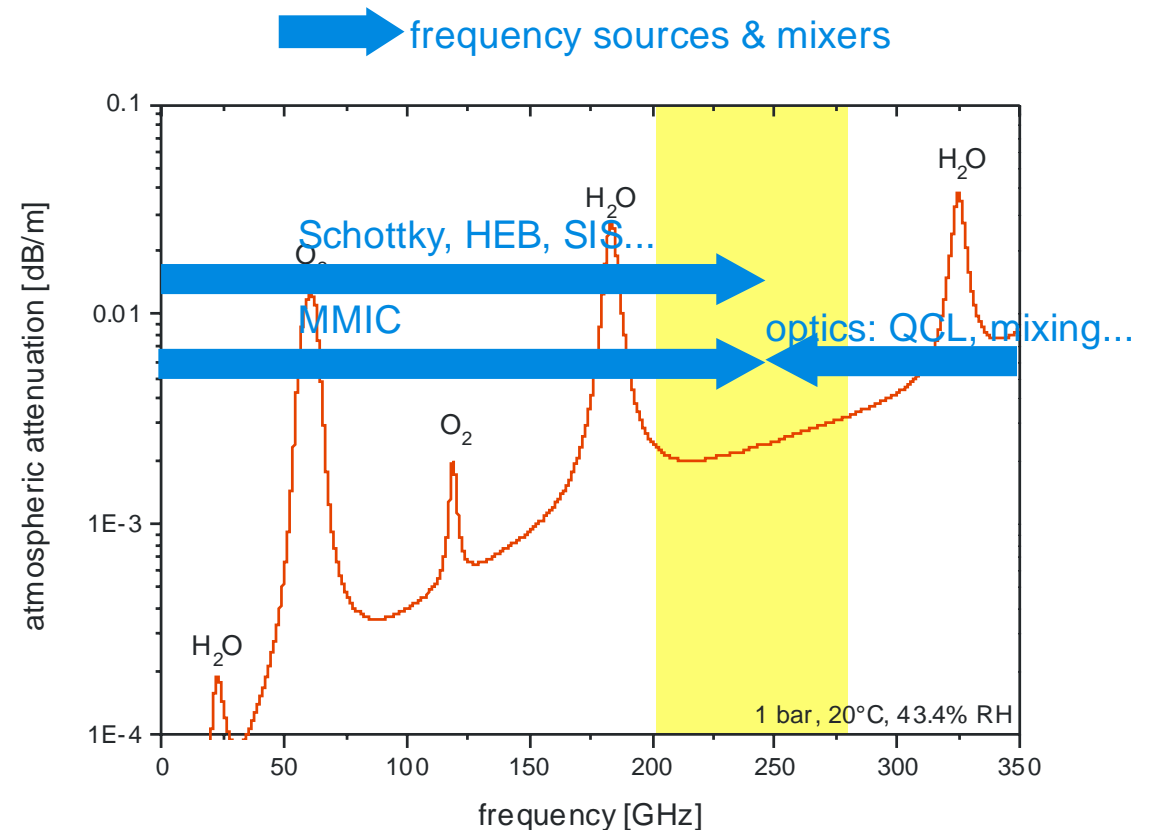
Motivation for 200 – 300 GHz Communication

- Multi Gbit/s wireless capability
- **Point-to-point**
 - **Fiber-over-radio**
 - **Radio-over-fiber (e.g. TV)**
- Telecom base stations
 - Backhaul
 - Pico-cells
 - Last mile / fiber to the home
- **Intra-machine communication**
 - **Sensor readout**
 - **Board-to-Board**



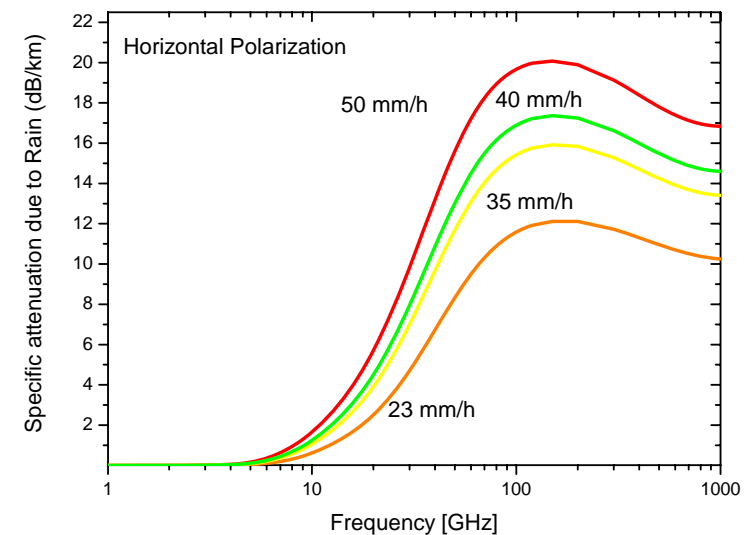
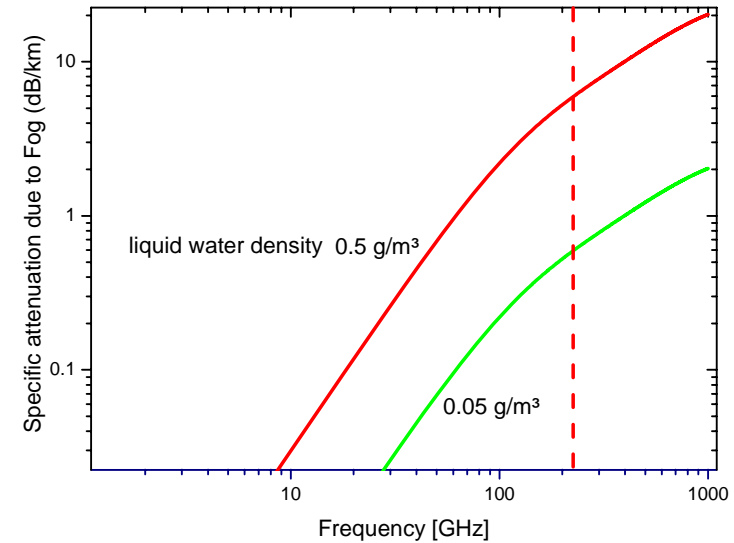
Technologies for 200 – 300 GHz Communication

- Passives/diodes:
e. g. Schottky
- Nonlinear optical
- **Active MMIC**
 - Multi-functional
 - Highly compact
 - Easy-to-deploy
 - Cost efficient



Atmospheric Attenuation

- Broad atmospheric window from 200 to 300 GHz
- Clear sky:
2 – 4 dB/km
- Adverse weather
 - Fog: 1 - 6 dB/km
 - Rain: 10 - 20 dB/km



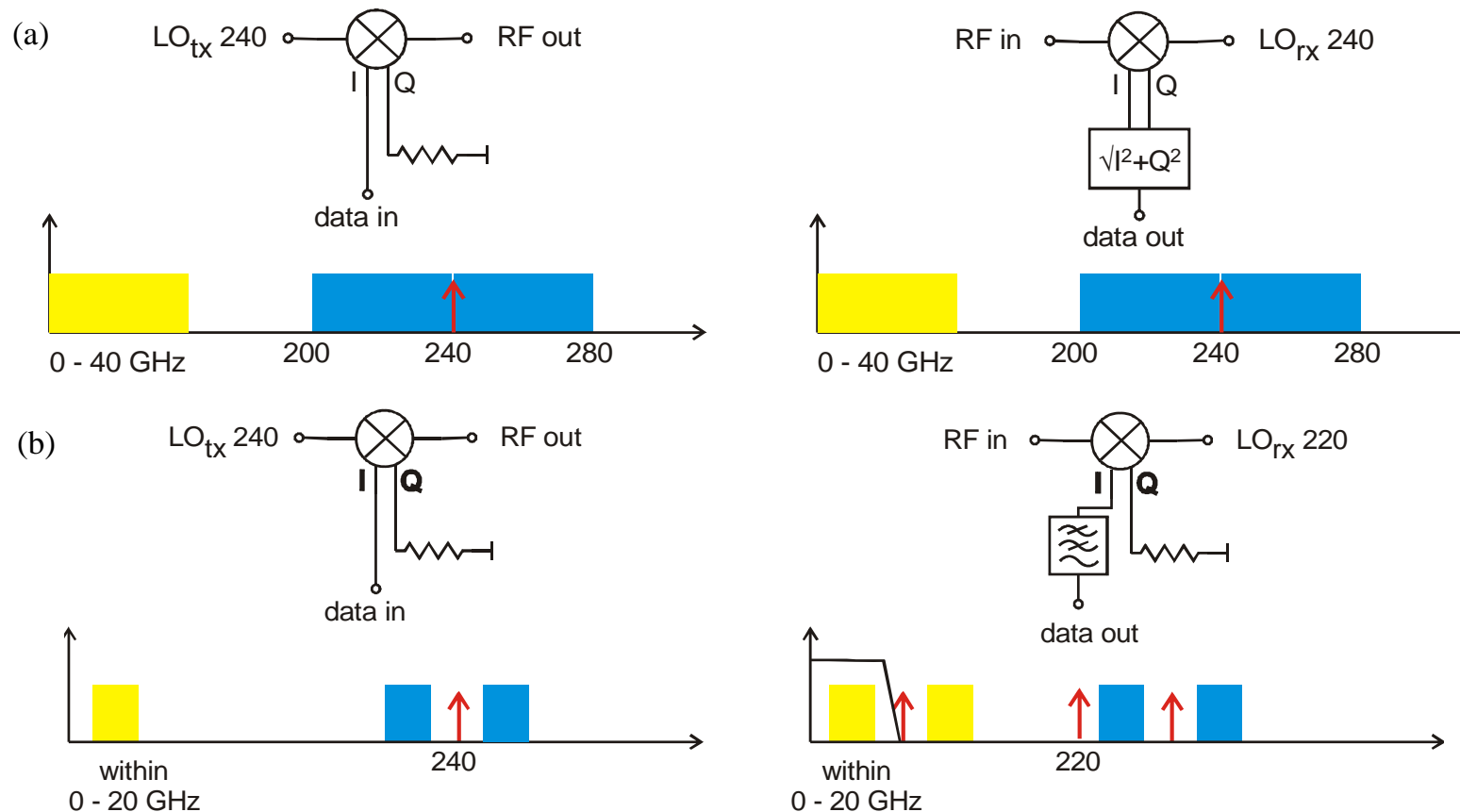
Source: ITU-Recommendation ITU-R P.676-8

Outline

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- **Frontend Architecture**
- Enabling MMIC Technology
- MMICs for Broadband Communication
- First 220 GHz Link Demonstrations

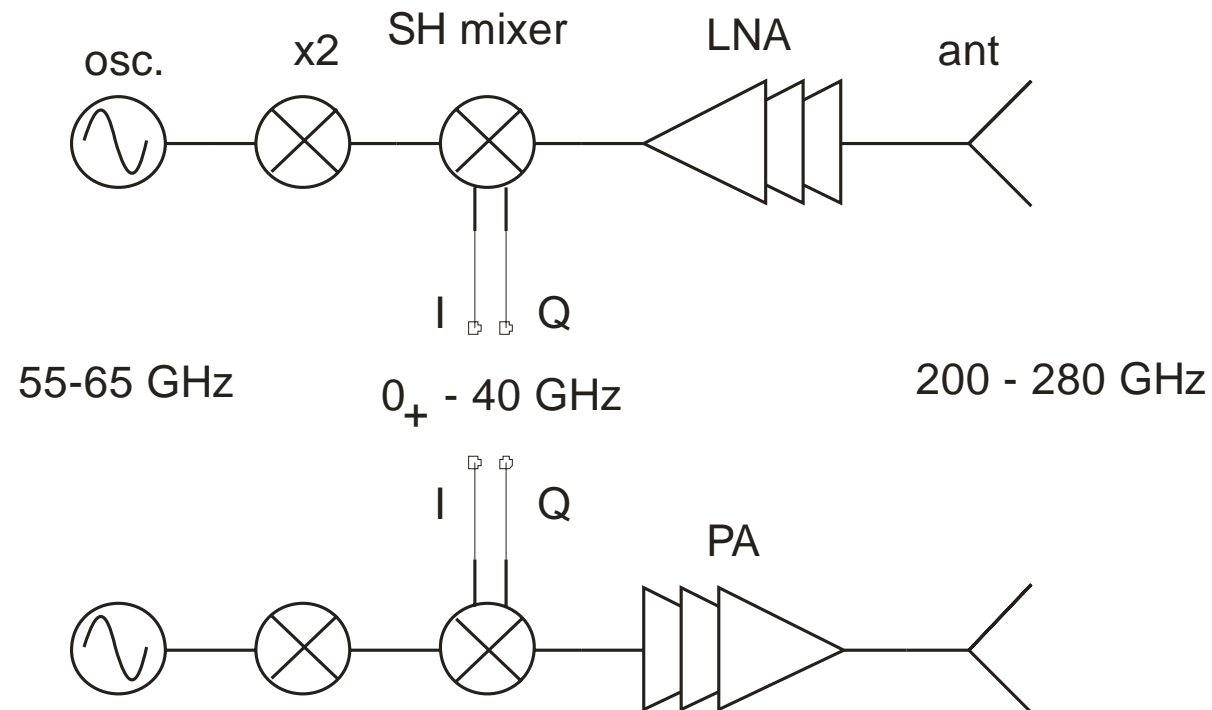
System Considerations

- Goal: incoherent transmission of APSK and >10 Gbit/s OOK signals
- Direct detection (only OOK) or zero-IF (a) with IQ receiver and rectification/summation
- Super-heterodyne (b): Single-ended and IQ mixers are possible
- Coherent detection: challenging due to probably inadequate carrier phase noise



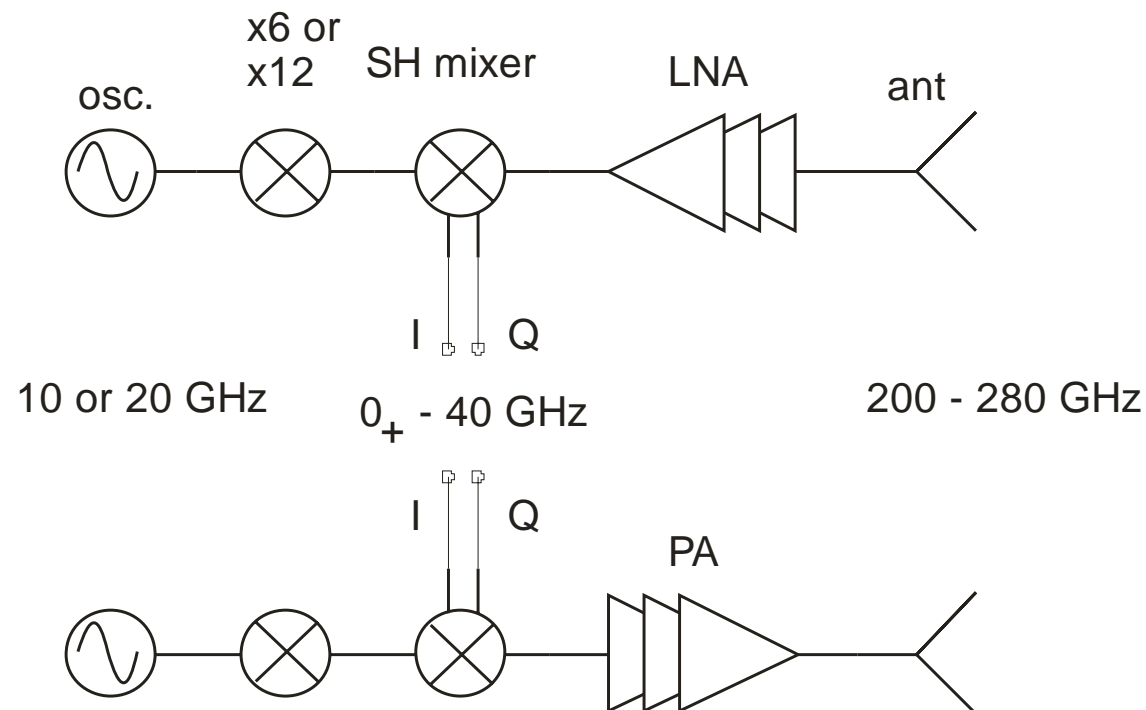
MMIC Frontend Architecture (1)

- Use broadband (~55-65 GHz) VCOs which will become available for 60 GHz Wireless



MMIC Frontend Architecture (2)

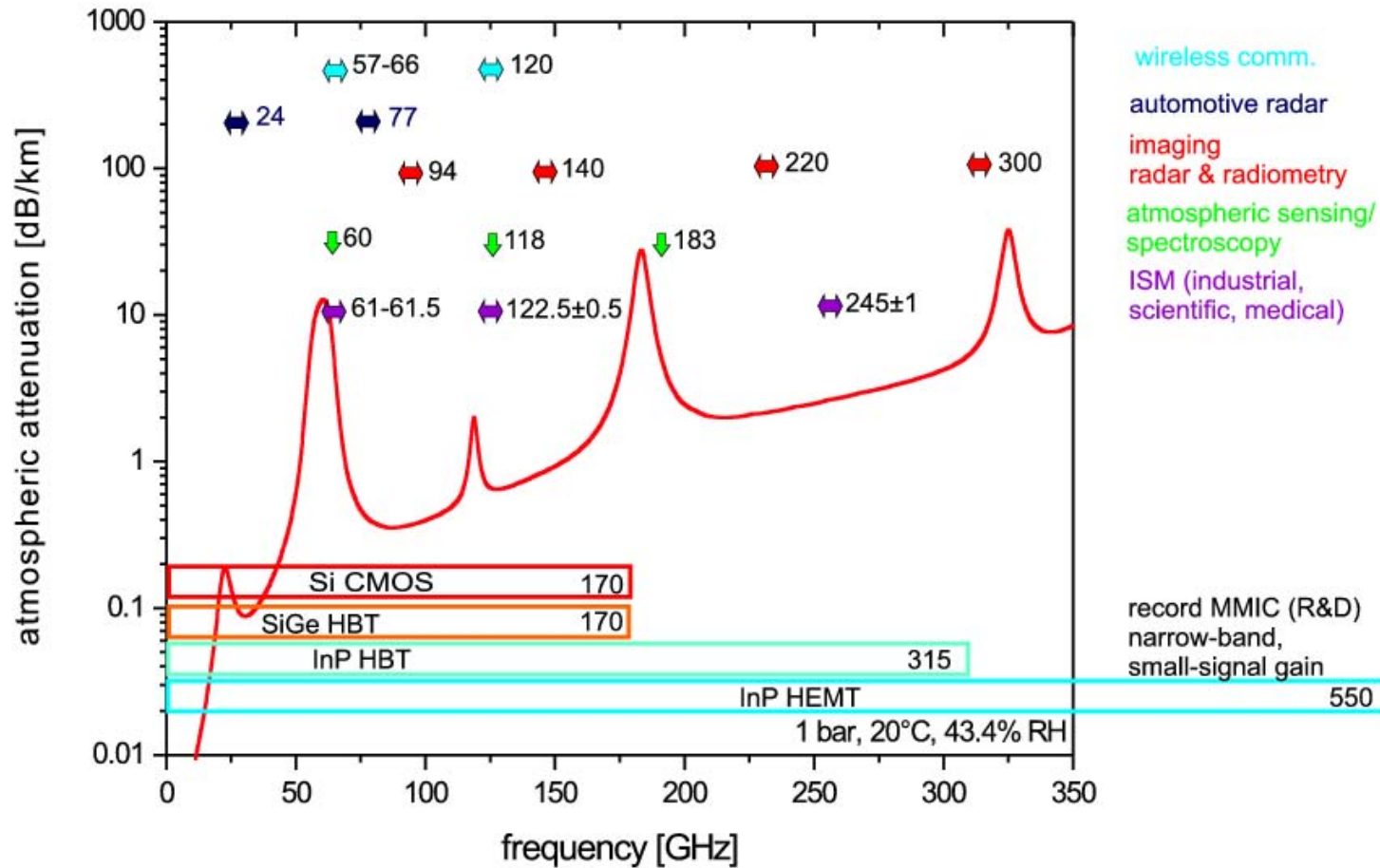
- Use commercially available 10 GHz or 20 GHz VCOs in combination with a frequency multiplier-by-twelve or –by-six



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MMIC Technology Candidates

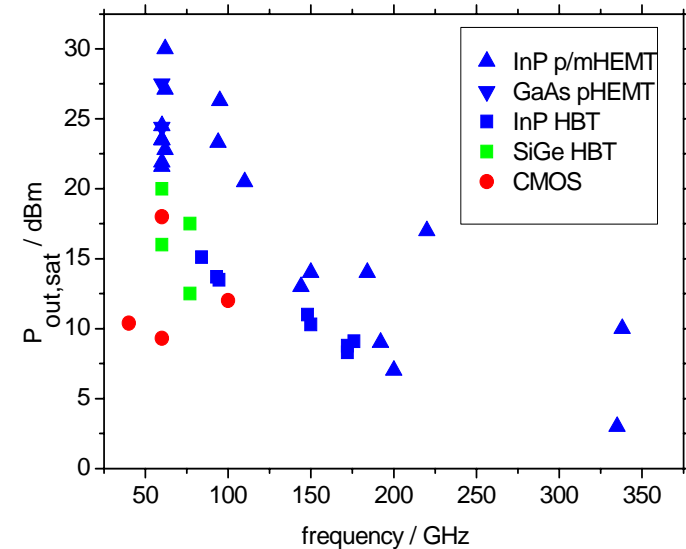
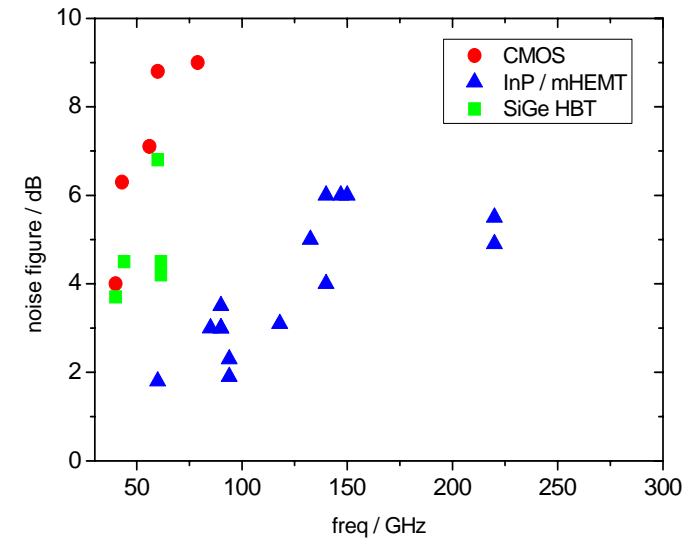


State-of-the-Art

InP HEMTs / GaAs mHEMTs

- LNAs
 - Amplifiers up to 550 GHz
 - NF 4.8 dB at 210 GHz (on-wafer)
 - NF 8.4 dB at 340 GHz (waveguide module)

- PAs
 - 17 dBm at 220 GHz (module)
 - 10 dBm at 338 GHz (module)



Why metamorphic?

Metamorphic and InP HEMTs :

- different substrates
- identical active layers

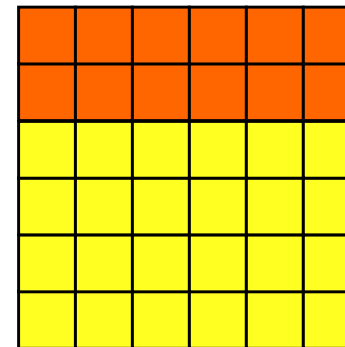
Advantages

- better mechanical stability
- high quality substrates up to 6"
- different lattice constants

Disadvantage

- additional growth effort

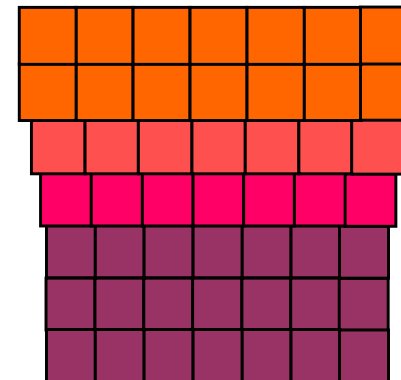
InP HEMT



InGaAs/InAlAs

InP

mHEMT

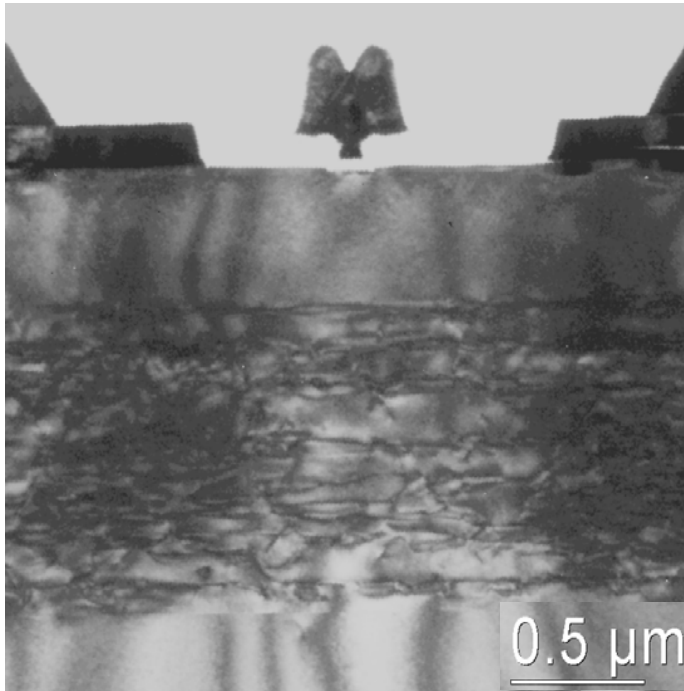


InGaAs/InAlAs

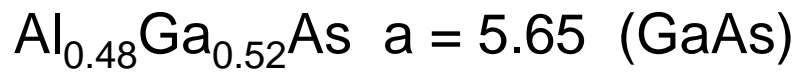
Metamorphic
buffer

GaAs

Epitaxy

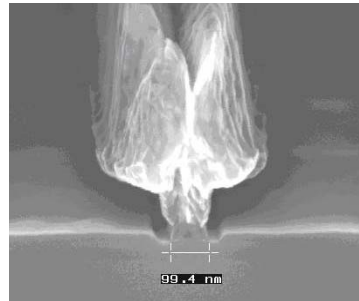


Material	Doping	Remarks
$\text{In}_{0.53}\text{Ga}_{0.47}\text{As}$	Si	cap
$\text{In}_{0.52}\text{Al}_{0.48}\text{As}$	n.i.d.	Schottky barrier
	Si	δ -doping
$\text{In}_{0.52}\text{Al}_{0.48}\text{As}$	n.i.d.	spacer
$\text{In}_x\text{Ga}_{1-x}\text{As}$	n.i.d.	channel
$\text{In}_{0.52}\text{Al}_{0.48}\text{As}$	n.i.d.	buffer
$\text{In}_{0.52}\text{Al}_{0.48}\text{As}$	n.i.d.	metamorphic buffer
$\text{Ga}_{0.52}\text{Al}_{0.48}\text{As}$		

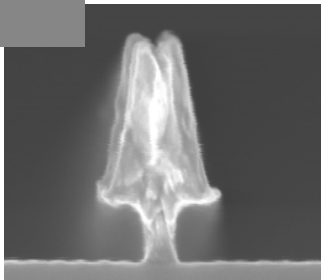


4" si GaAs substrate

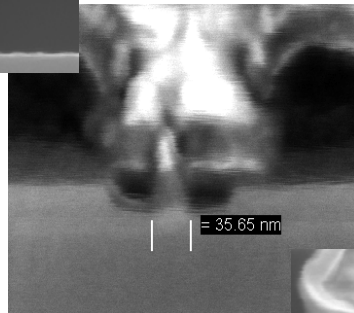
Transistor Scaling



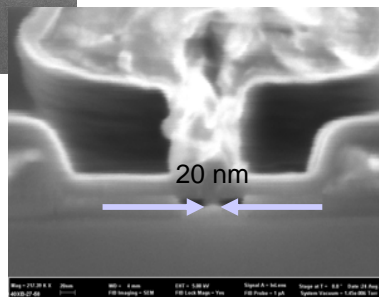
100 nm
 $f_T / f_{max} = 220/300$ GHz



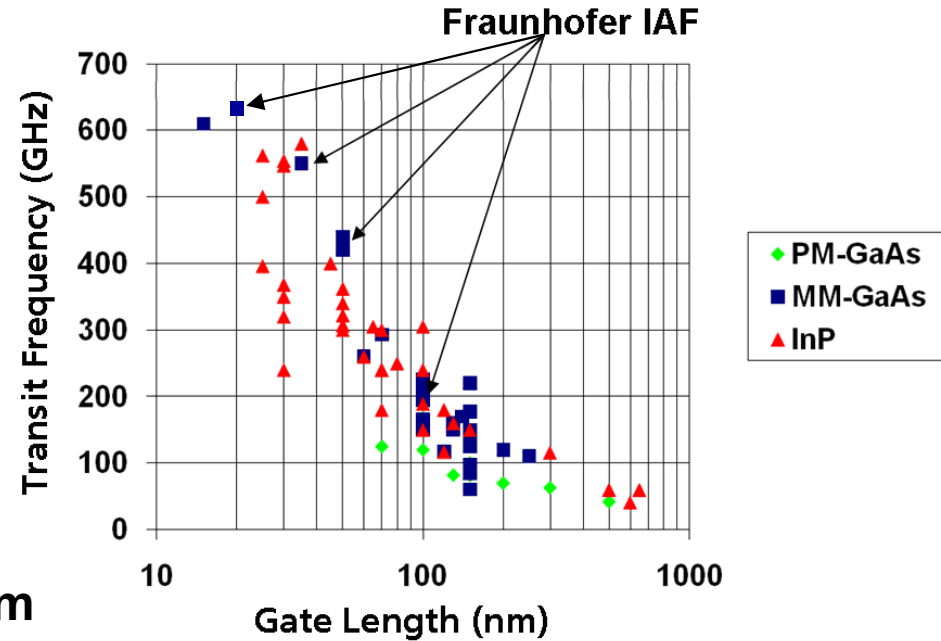
50 nm
375/600 GHz



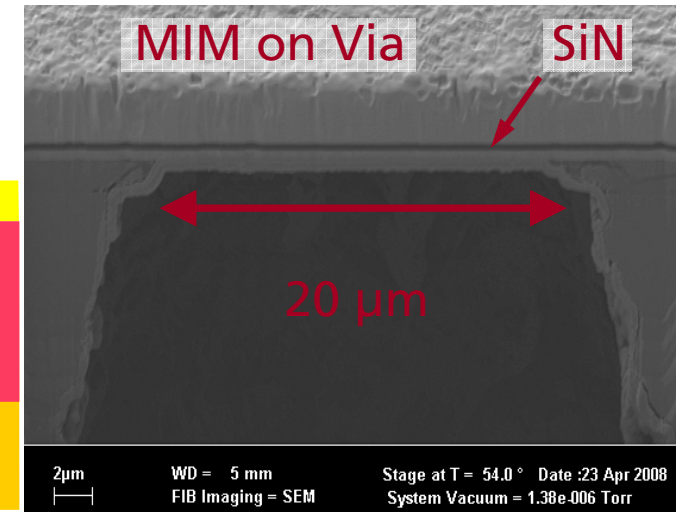
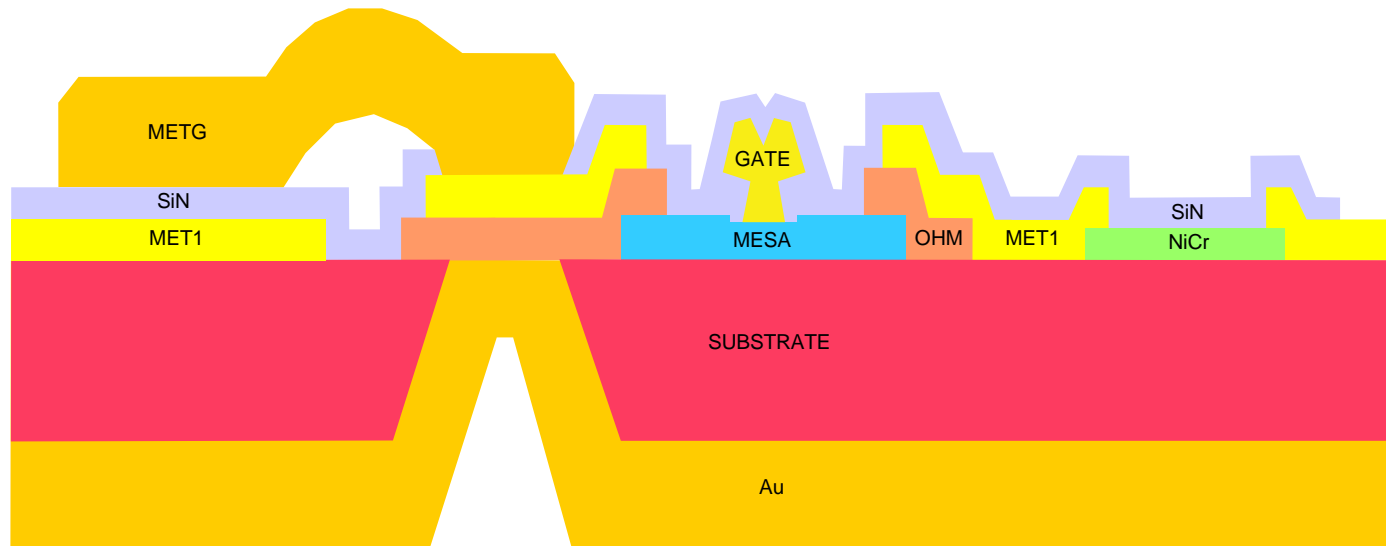
35 nm
515/900 GHz



20 nm
Feasibility demonstrated
Ongoing development (epi, gate...)



MMIC Process



Frontside

- Passives: MIM, resistors, etc.
- SiN passivation
- Microstrip or grounded coplanar
- 50 μm and 14 μm ground-to-ground spacing

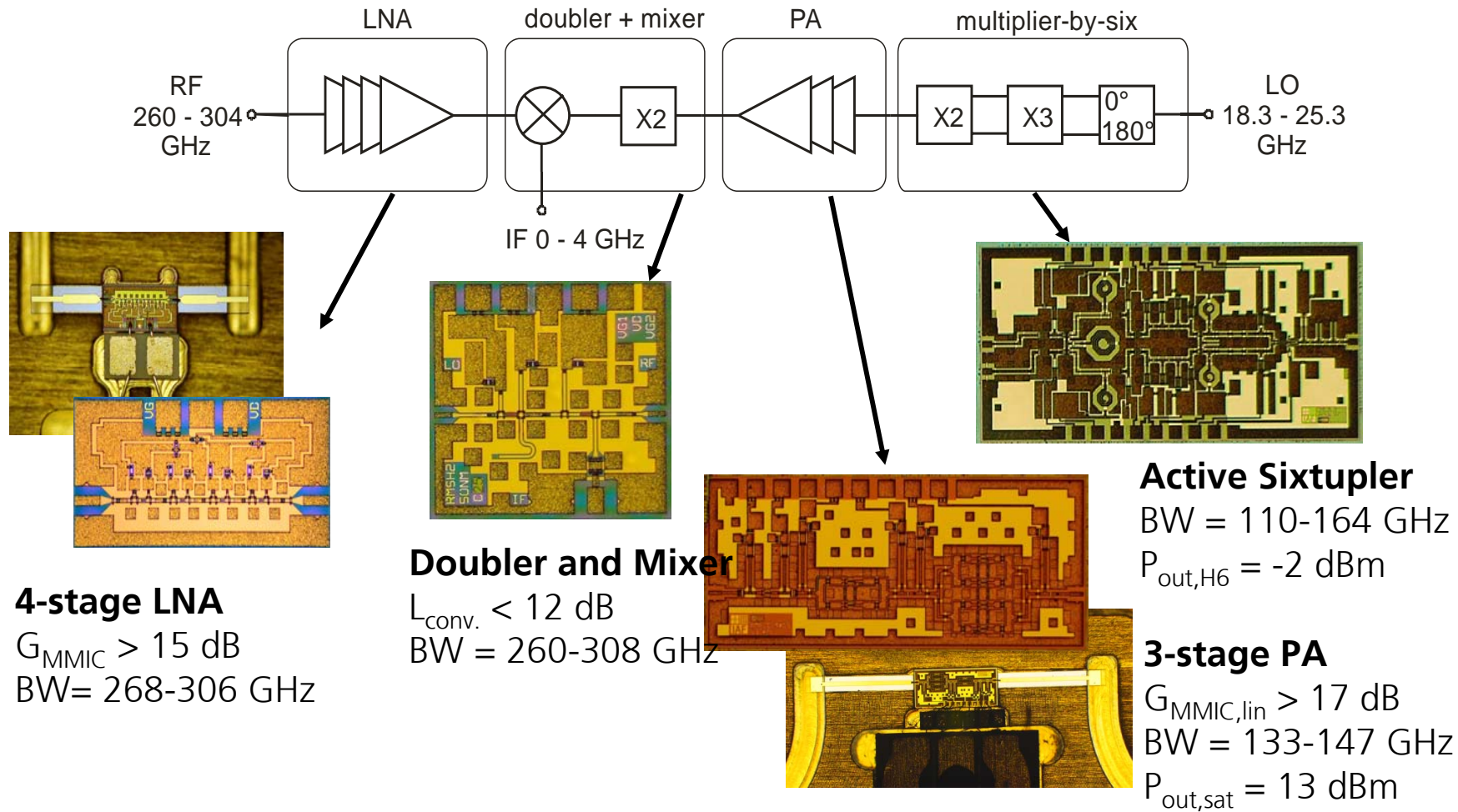
Backside

- substrate mode suppression
- 50 μm wafer thinning
- 20 μm via holes

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- Enabling MMIC Technology
- **MMICs for Broadband Communication**
 - Low Noise Amplification
 - Frequency Multiplication
 - Frequency Conversion
 - Receivers and Transmitters
- First 220 GHz Link Demonstrations

Towards an all-MMIC-based 300 GHz Receiver

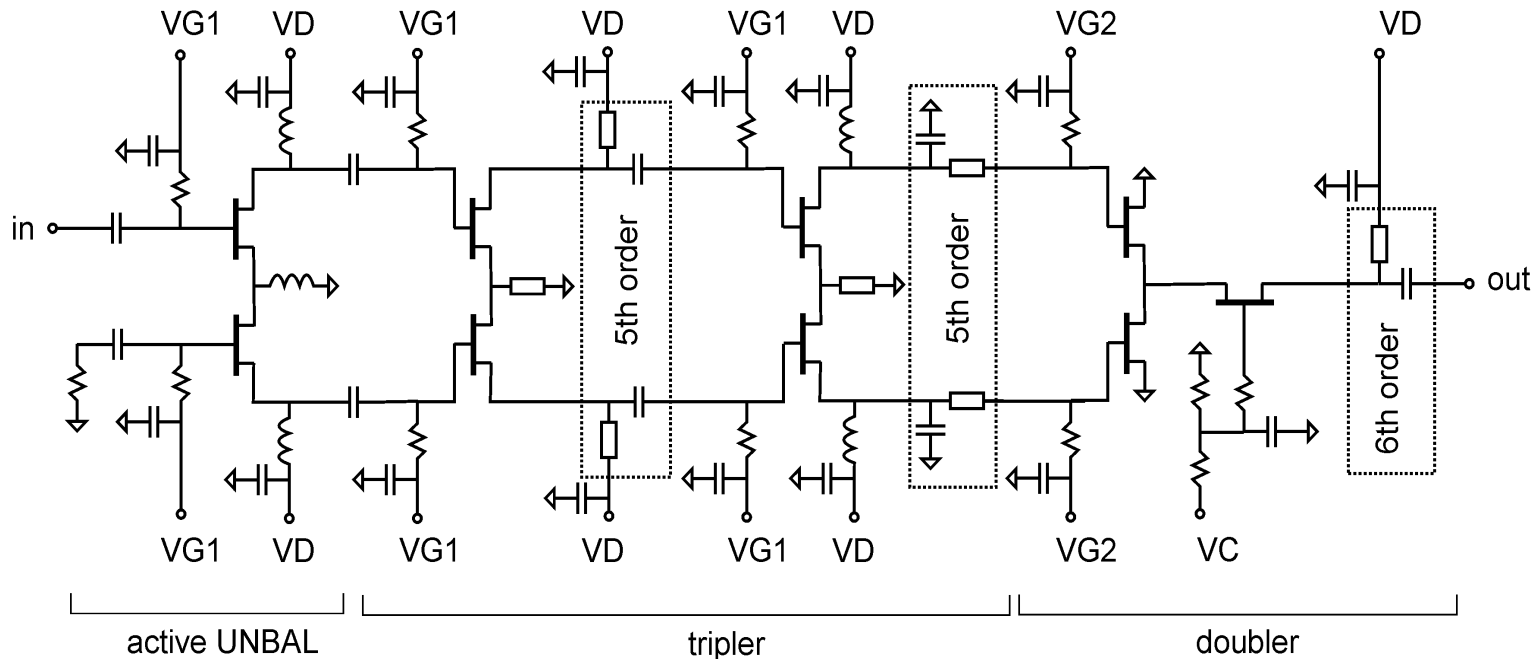


D-Band Frequency Multiplier-by-Six

Active UNBAL
Differential stage

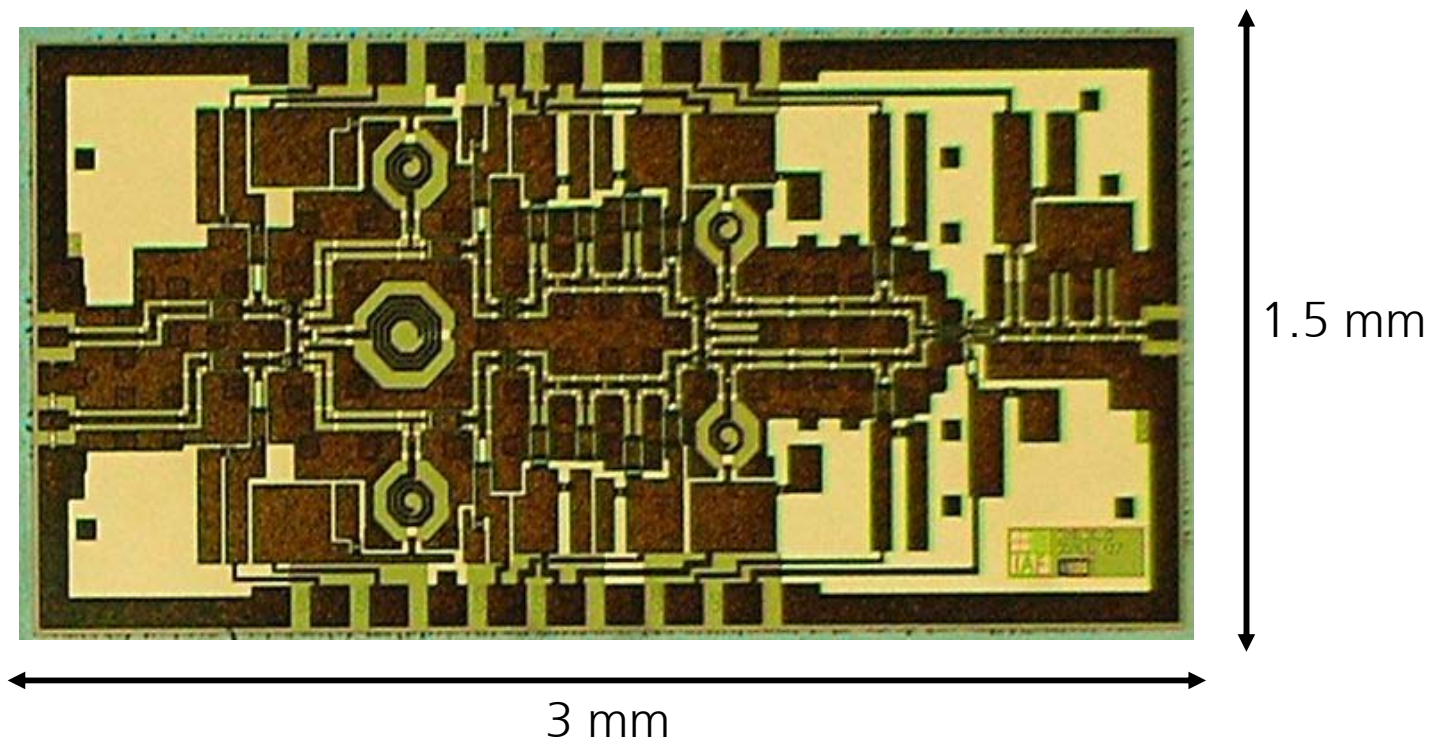
Balanced Tripler
2-stage
class A FETs in compression
Broadband HP and TP-type matching
Even-order rejection

Balanced Doubler
Class-B push-push FETs
Cascode topology



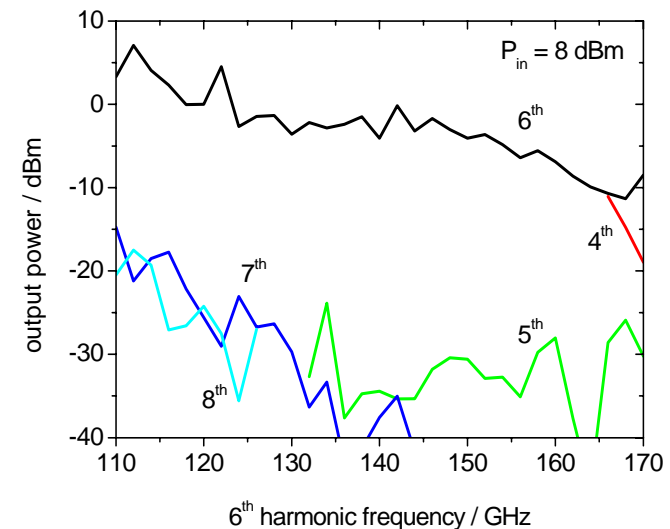
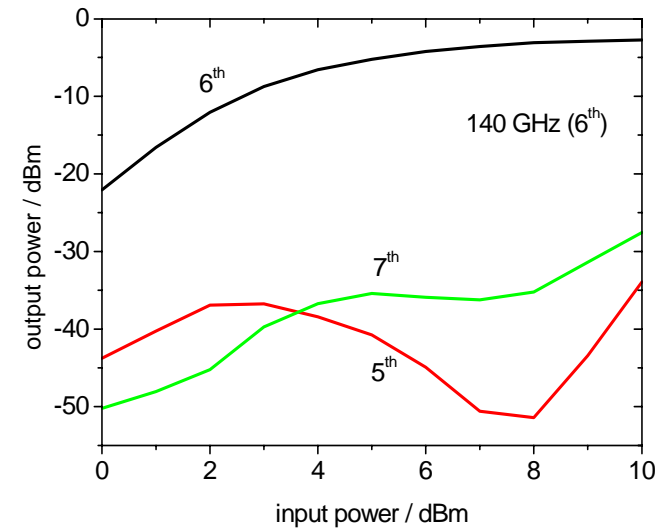
D-Band Frequency Multiplier-by-Six

- 100 nm mHEMT technology
 - $f_T / f_{\max} = 220 / 300$ GHz
- Grounded coplanar TRL environment



D-Band Frequency Multiplier-by-Six

- Operating range: <110 – 164 GHz
- Bandwidth: 54 GHz (39 %)
- Output power: -2 dBm @ 140 GHz
- Conversion loss: 10 dB
- Spectral purity: > 20 dBc
- Supply
 - drain voltage: 2.2 V
 - current: 180 mA
 - power: 396 mW



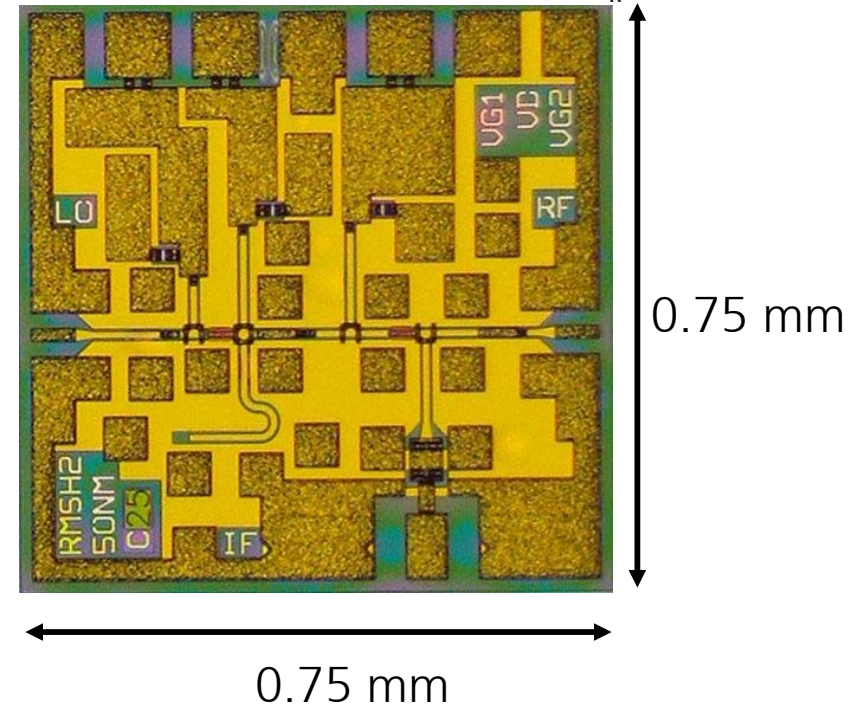
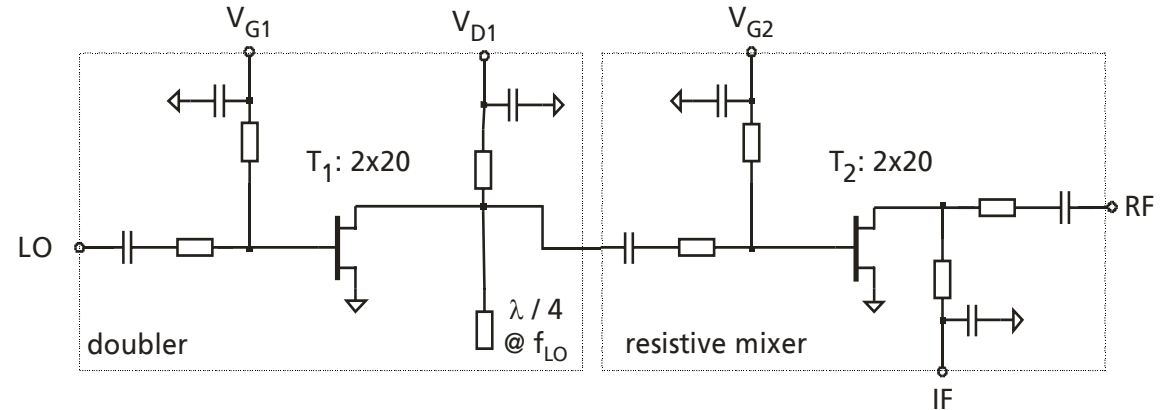
300 GHz Frequency Doubler and Mixer

- **Doubler**

- 50 nm mHEMT
- 2x20 μm Class-B FET
- Fundamental $\lambda/4$ stub
- Also as stand-alone MMIC

- **Mixer**

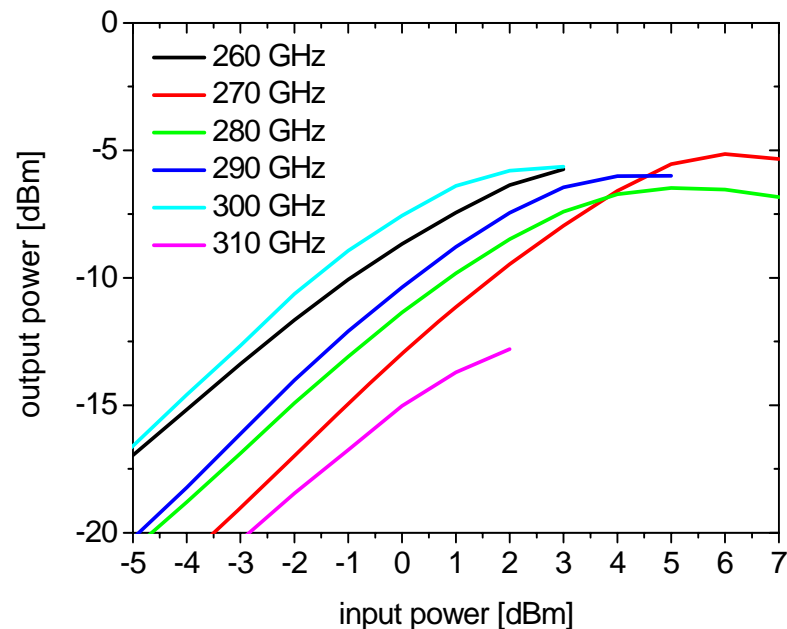
- 50 nm mHEMT
- Resistive FET



300 GHz Frequency Doubler and Mixer

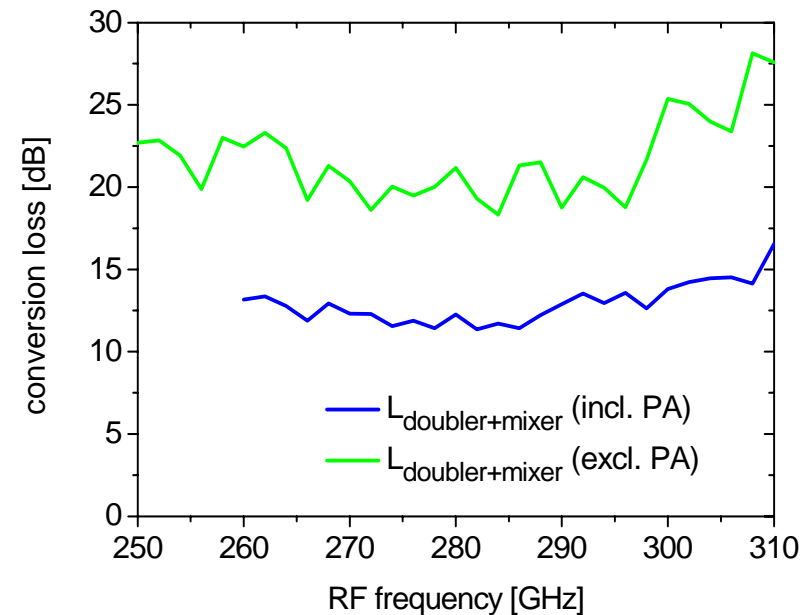
Doubler

- Output power: -6 dBm
- Frequency range: 260 – 300 GHz



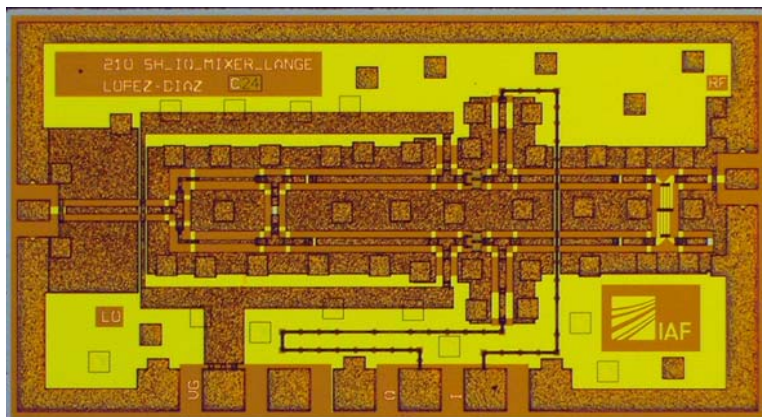
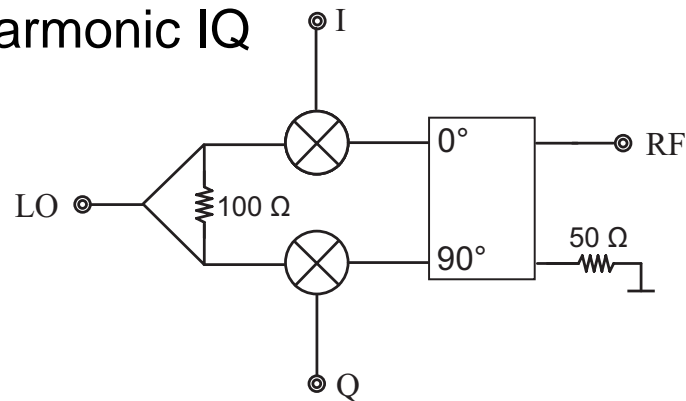
Doubler + Mixer

- Conversion gain
 - @ 0 dBm PLO (w/o PA): -20 dB
 - @ 3 dBm PLO (w/ PA): -12 dB
 - w/ LNA: 3 dB



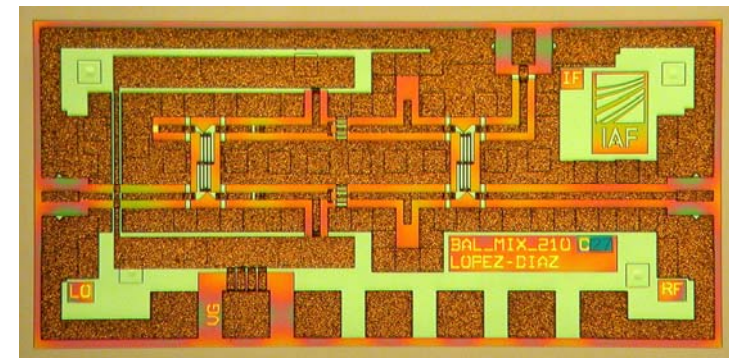
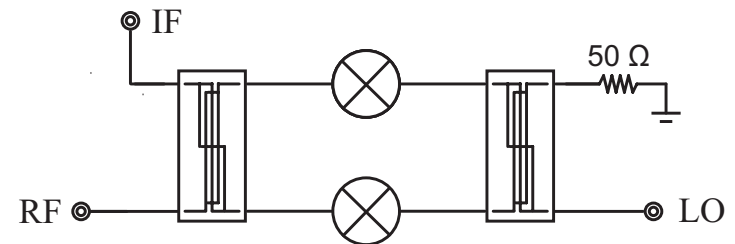
200-300 GHz Mixers

Subharmonic IQ



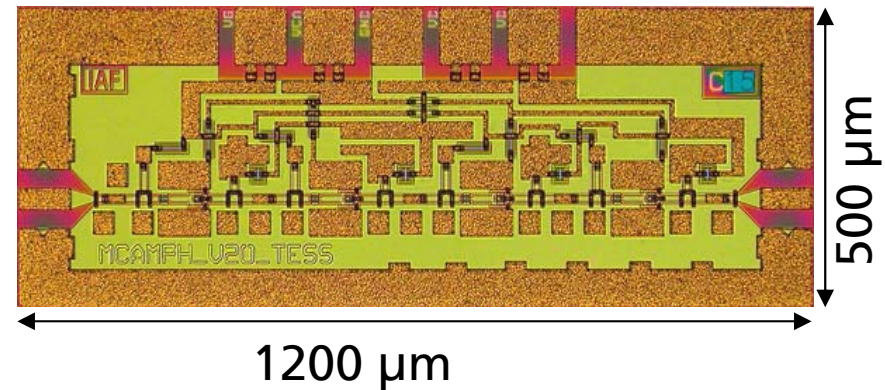
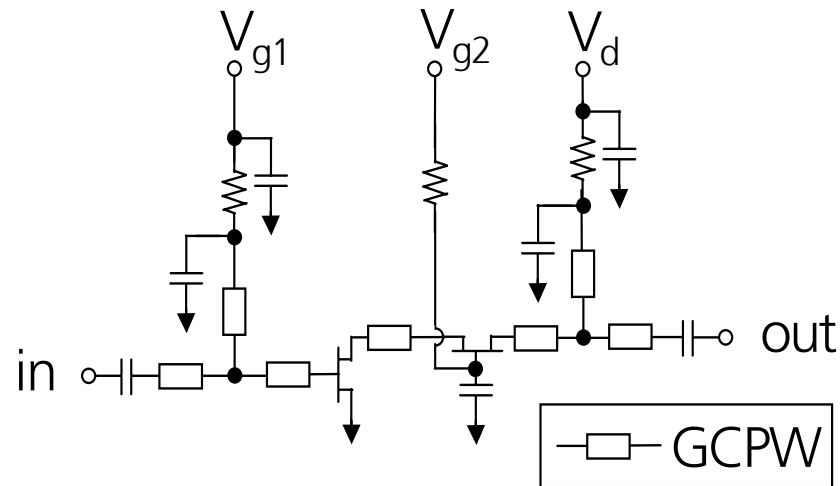
Conv. Loss 18.4 dB @ 2dBm P_{LO}
Phase imbalance +/-5° @ 188-220 GHz

Fundamental balanced



RF 160-260 GHz, IF 0-50 GHz
Conv. Loss <20 dB @ 0 dBm P_{LO}

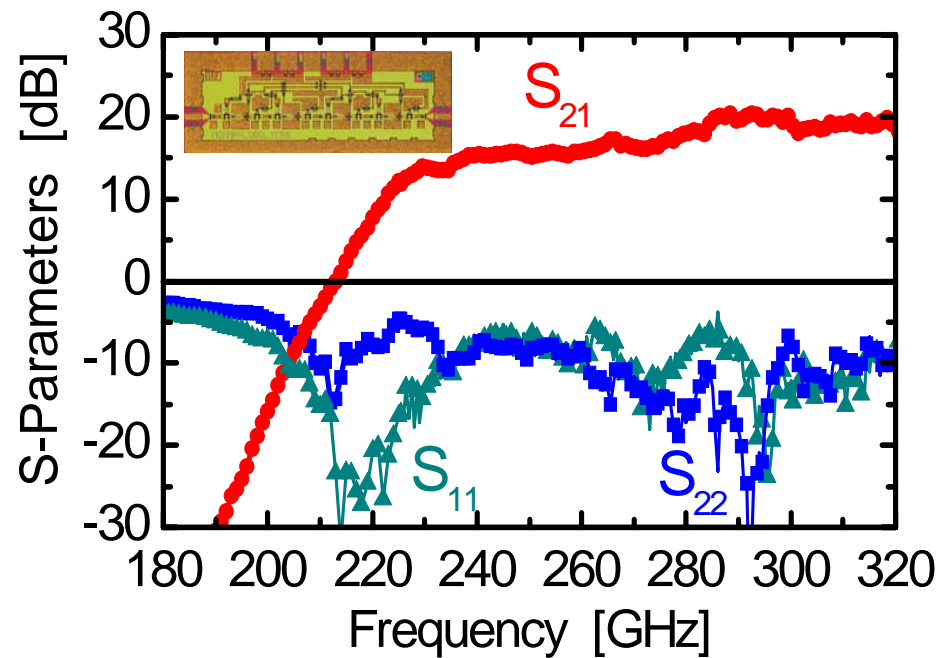
H-Band Cascode mHEMT Amplifier S-MMIC



- 50nm mHEMT technology
- cascode mHEMT
- gate width: $2 \times 10 \mu\text{m}$
- chip size: 0.6 mm^2

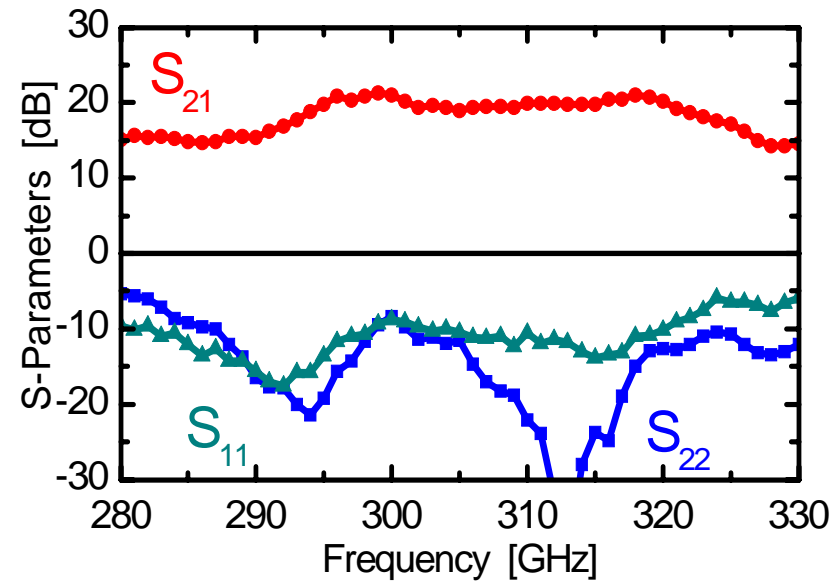
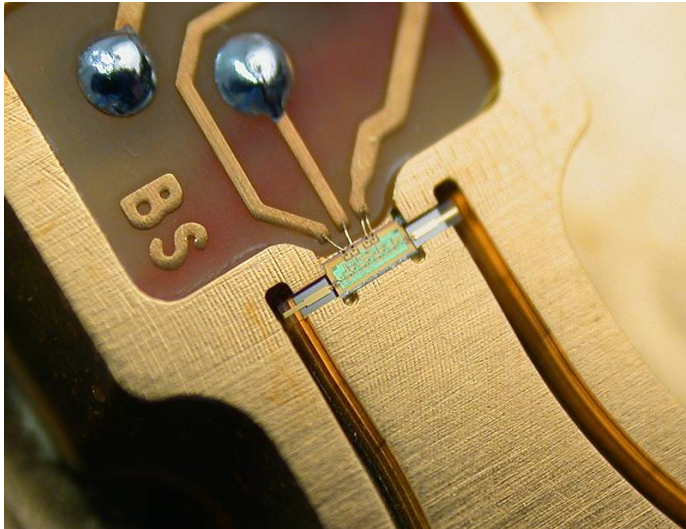
- reactively matched
- GCPW line impedance = 50Ω

H-Band Cascode mHEMT Amplifier S-MMIC



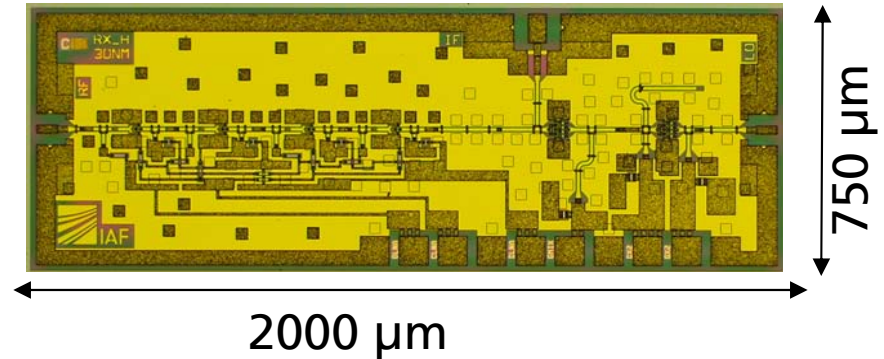
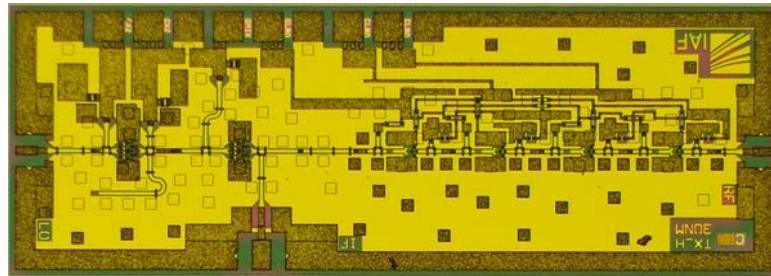
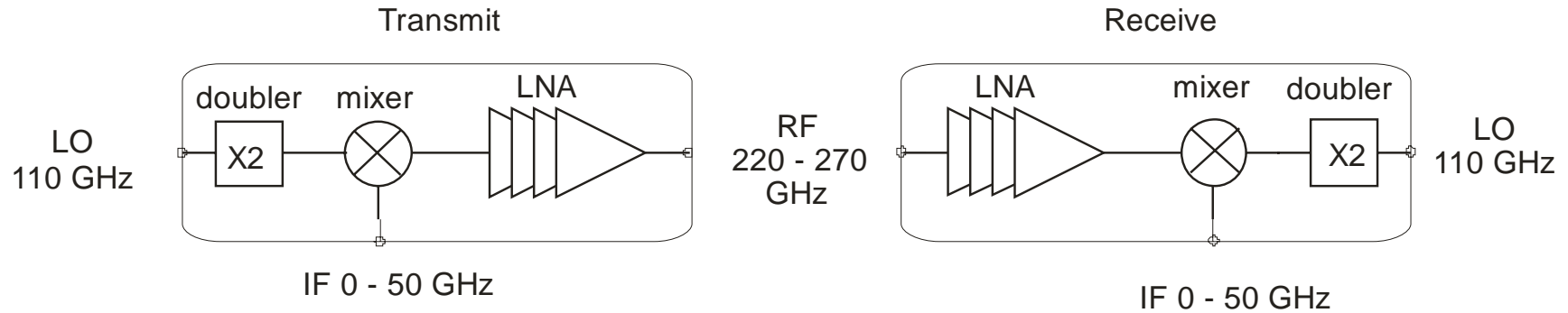
- gain: 19.5 dB @ 320 GHz
- gain: > 15.0 dB @ 240...320 GHz
- simulated NF = 7.3 dB @ 300 GHz
- power consumption: 90 mW ($V_d = 2.0$ V, $I_d = 45$ mA)

Four-Stage 300 GHz Amplifier Module ($L_g = 50$ nm)



- power consumption:
530 mW ($V = 5.0$ V, $I = 106$ mA)
- gain: >19 dB @ 295...320 GHz
- max. gain: 21 dB @ 300 GHz
- matching: -10 dB @ 285...320 GHz

Multifunctional Integration



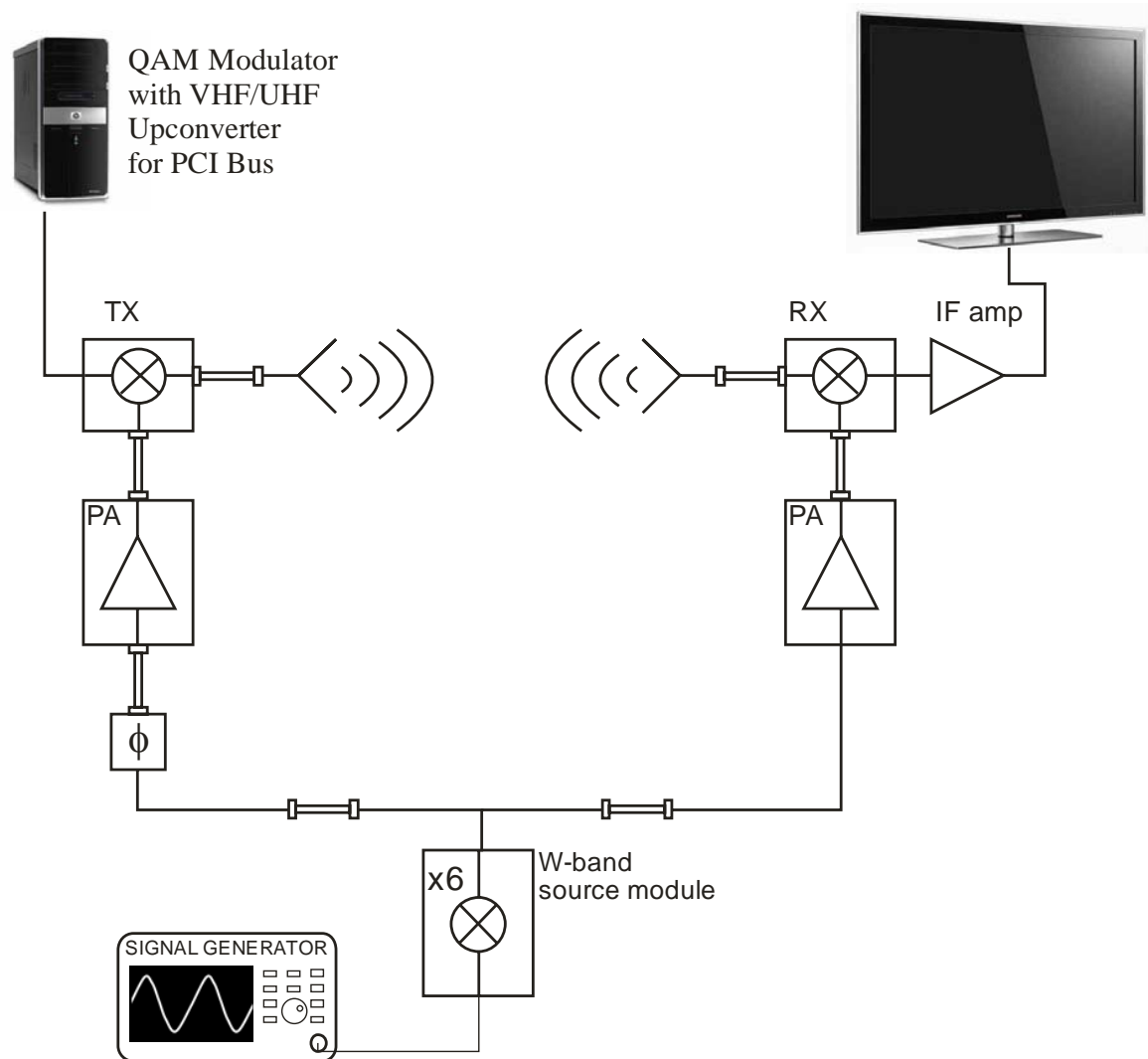
- Wideband IF
- Mirrored LNA in Transmitter
- Identical chip interface for packaging
- Receive conversion gain: 3.5 dB
- RF transmit power: up to -1.5 dBm (LNA saturation)

Outline

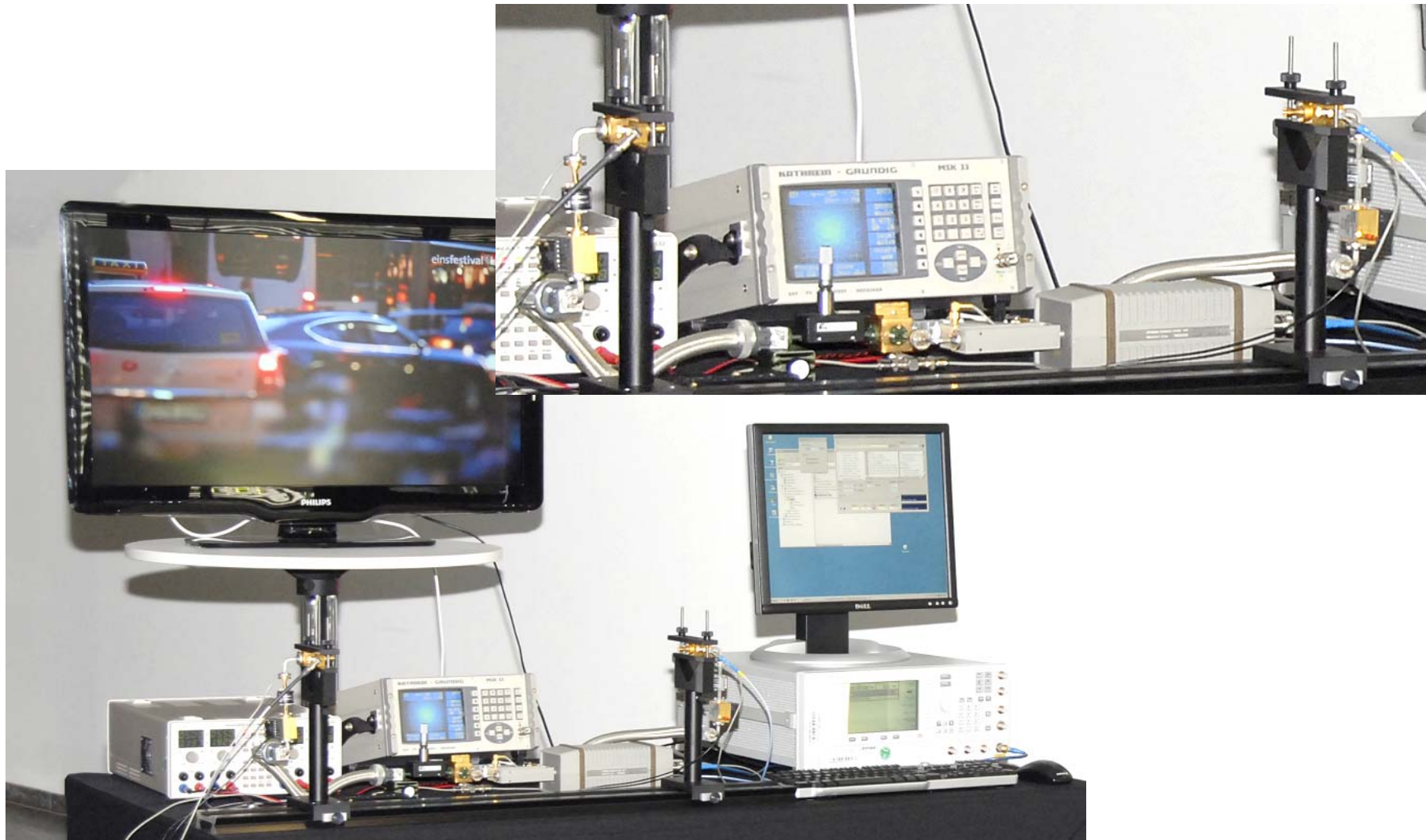
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DVB-C Transmission at 220 GHz

- Carrier @ 220 GHz (LO @ 110 GHz)
- DVB-C media stream @ 64 QAM
- IF amplification 33 dB



DVB-C Transmission at 220 GHz



Summary & Outlook

- Fully MMIC-based wireless transmission at 220 GHz demonstrated
- Broadband, high performance MMIC components based on metamorphic HEMTs are available in the frequency range 200 – 300 GHz

Ongoing activities target

- Fully integrated wideband transmit and receive MMICs featuring
 - Subharmonic IQ mixers
 - PA stages in transmitters (goal: wideband 10 dBm P_{out})
- Experiments for
 - Coherent OOK transmission (eye diagrams)
 - Incoherent super-heterodyne transmission

Thank you for your attention!

Ingmar Kallfass
Prof. Dr.-Ing.

Fraunhofer Institute
for Applied Solid State Physics

Tullastraße 72
D-79108 Freiburg/Germany
Phone: +49 (0)761 5159 486
Fax: +49 (0)761 5159 71486
Email: ingmar.kallfass@iaf.fraunhofer.de
Web: www.iaf.fraunhofer.de

Karlsruher Institut für Technologie (KIT)
Institut für Hochfrequenztechnik und Elektronik

Kaiserstraße 12
76131 Karlsruhe
Tel.: +49-(0)721-608-2525
Fax: +49-(0)721-691865
E-Mail: ingmar.kallfass@kit.edu
Web: www.kit.edu ; www.ihe.kit.edu